

Tungsten Hexafluoride, WF₆

Description

Tungsten Hexafluoride (WF₆) is an odorless, toxic, corrosive, liquefied gas. WF6 is commonly used in chemical vapor deposition for the semiconductor industry.

Properties	Units		Grades	
Tungsten Hexafluoride, WF ₆		99.99%	99.995%	99.999%
Carbon Dioxide, CO2	(ppmv)	<10	<1.0	<0.5
Carbon Monoxide, CO	(ppmv)	<10	<1.0	<0.5
Hydrogen Fluoride, HF	(ppmv)	<20	<10	<5
Nitrogen, N ₂	(ppmv)	<10	<5.0	<1.0
Oxygen/Argon, O ₂ / Ar	(ppmv)	<10	<5.0	<1.0
Silicon Tetrafluoride, SiF4	(ppmv)	<10	<1.0	<0.5
Sulfur Hexafluoride , SF_{6}	(ppmv)	<10	<1.0	<0.5
Tetrafluoromethane, CF4	(ppmv)	<100	<10	<1
Chromium (Cr)	(ppmw)	40	20	15
Iron (Fe)	(ppmw)	20	20	10
Potassium (K)	(ppmw)	20	10	5
Sodium (Na)	(ppmw)	20	10	5
Thorium (Th)	(ppmw)	10	10	5
Uranium (U)	(ppmw)	10	10	0.1
Total Metals	(ppmw)	1000	500	300

For specific values or requirements, please contact us.

About Inhance Technologies

Inhance Technologies is a leading provider of specialty chemicals, gases and material technologies in a wide range of industries, across four continents.

For more than 40 years, Inhance Technologies' world-class experts have been collaborating with customers globally to create customized solutions and offer exclusive technologies.



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